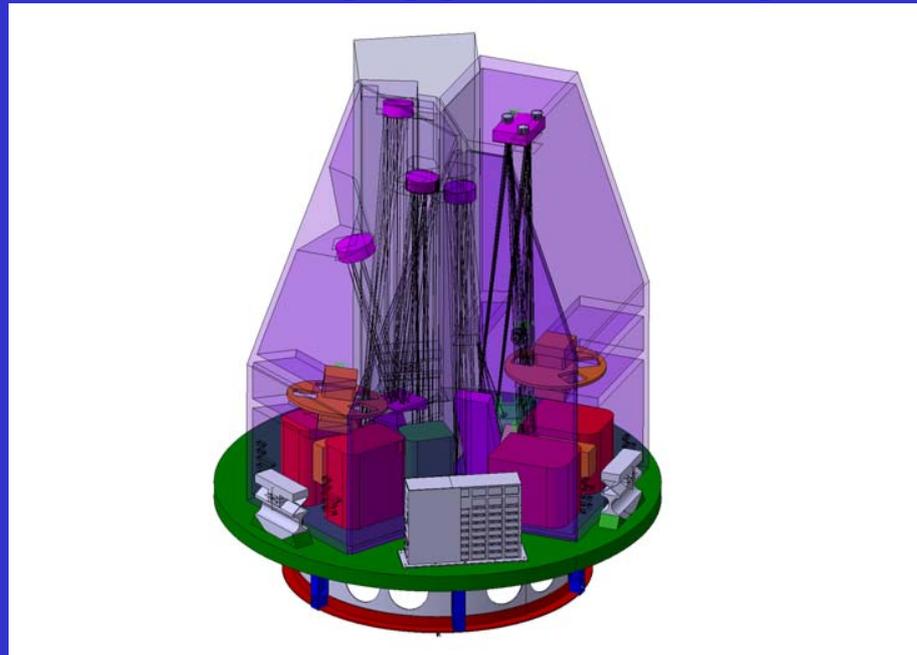


# WSO/UV Spectrographs



## The Expected Performance of WSO/HIRDES



@ El Escorial, 2007

N. Kappelmann

# WSO/UV Spectrographs

Flight Heritage:

MCP Detectors

FE Electronics

## Design Criteria

Wavelength Coverage : 103 – 310 nm

Spectral Resolution : > 50.000

Simultaneous Coverage : as far as possible

Minimum Sensitivity : S/N = 10 in  $10^h 16^{\text{mag}}$

# WSO/UV Spectrographs

## History of the High Resolution Double Echelle Spectrograph:

### *1990 – 1997 (Spectrum UV):*

- |             |                                     |
|-------------|-------------------------------------|
| 1992 - 1993 | Feasibility Study of HIRDES         |
| 1994 - 1997 | Financing of Technical Developments |

### *1998 – 2007 (WSO/UV):*

- |             |                           |
|-------------|---------------------------|
| 2000 - 2001 | HIRDES Phase – A - Study  |
| 2005 - 2006 | HIRDES Phase - B1 - Study |
| 2007        | Interfaces Study          |

# WSO/UV Spectrographs

## Design Criteria Phase B1

- Wavelength Coverage : 103 – 310 nm
- Spectral Resolution : > 50.000
- Simultaneous Coverage : as far as possible
- Possibility to Observe Bright Stars
- Improvement of FE of the MCP-Detector
- „Slit – Monitor“
- Reduction of Mechanisms

## High Resolution Double Echelle Spectrograph (HIRDES)

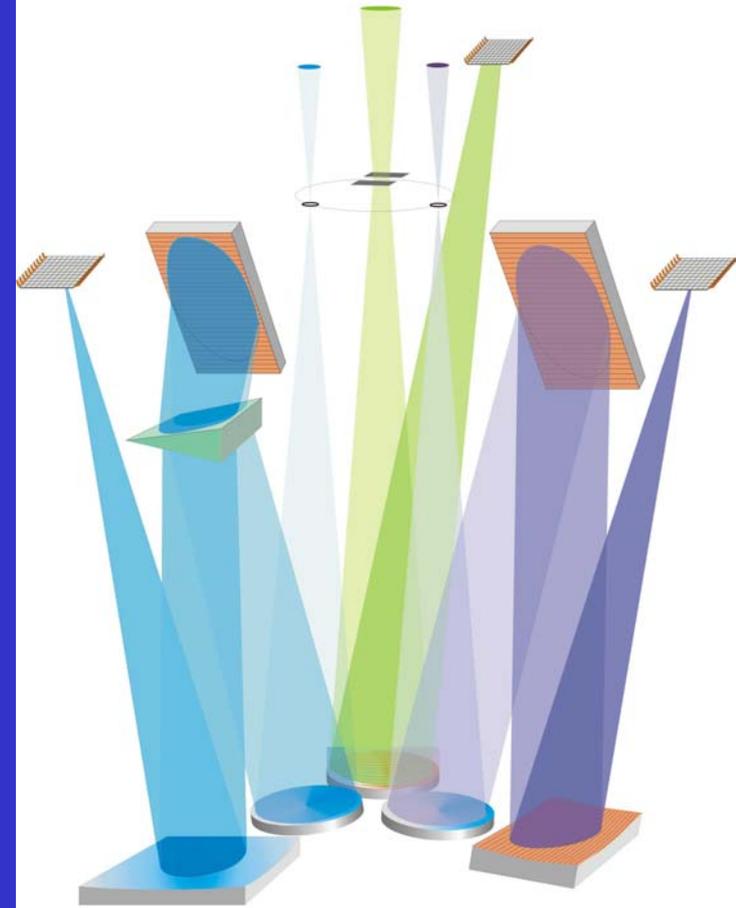
VUVES : 102.8 – 175.6 nm

$\lambda/\delta\lambda$  : 55.000

UVES : 174.5 – 310.0 nm

$\lambda/\delta\lambda$  : 50.000

## WSO-HIRDES



# WSO/UV Spectrographs

## LSS – Rowland Mounting

Detector: 40 mm (grating dispersion),  
40  $\mu\text{m}$  resolution (pixel-width)

## Resolving Power:

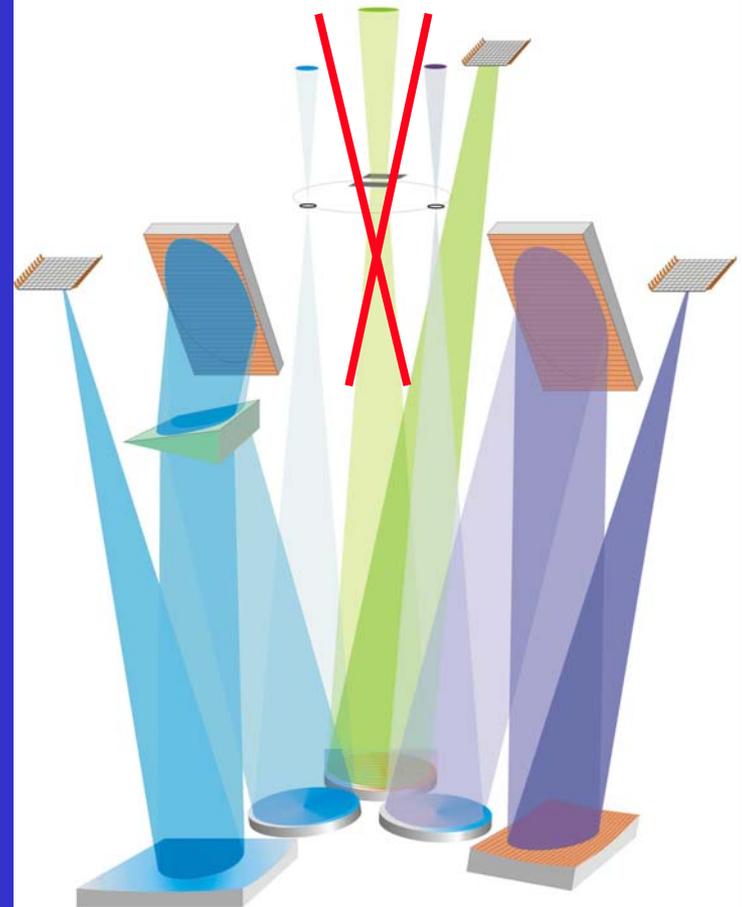
R=1000 140 nm – 200 nm

R= 500 120 nm – 240 nm

R= 320 103 nm – 310 nm

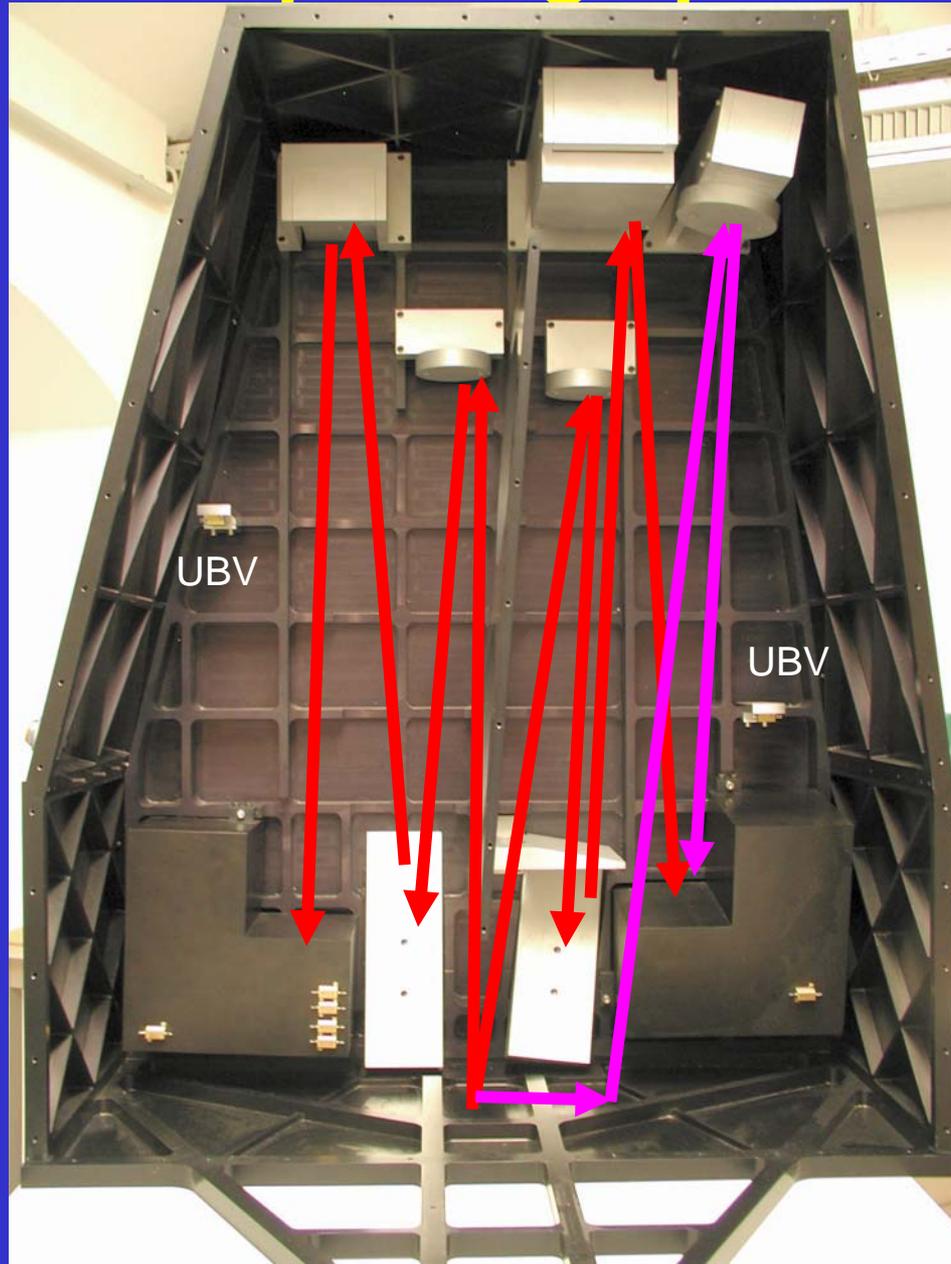
Spatial Resolution: 1 arcsec

## WSO-HIRDES



# WSO/UV Spectrographs

VUVES

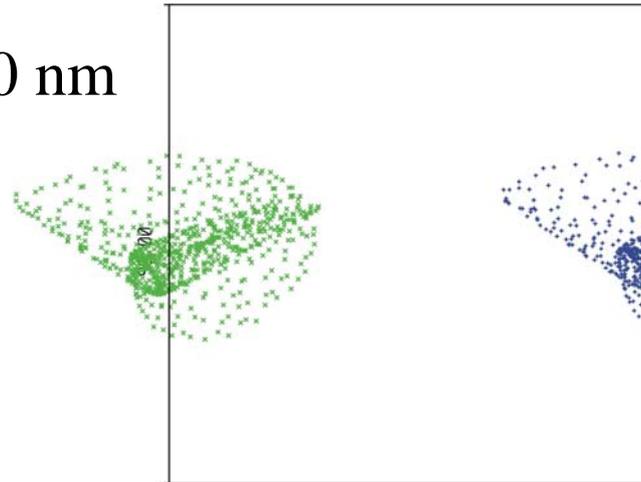


UVES

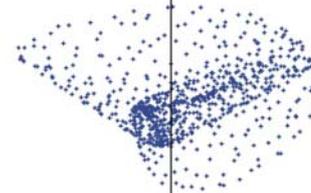
+ LSS

# WSO/UV Spectrographs

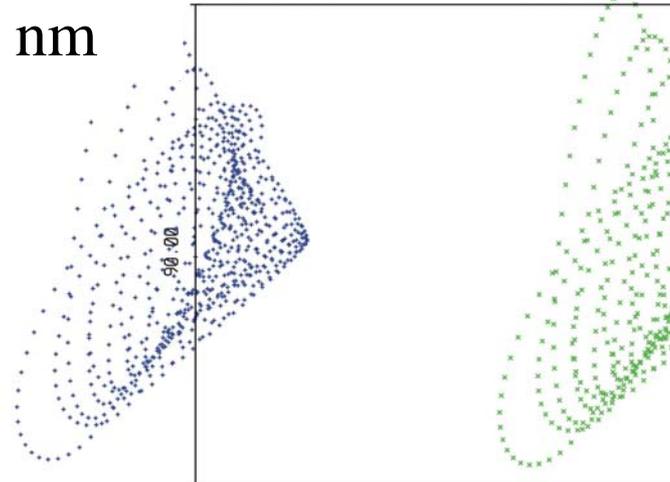
309.9800 nm



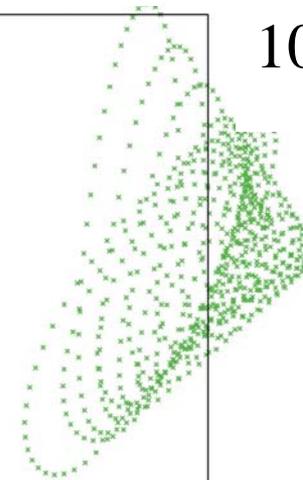
309.9862 nm



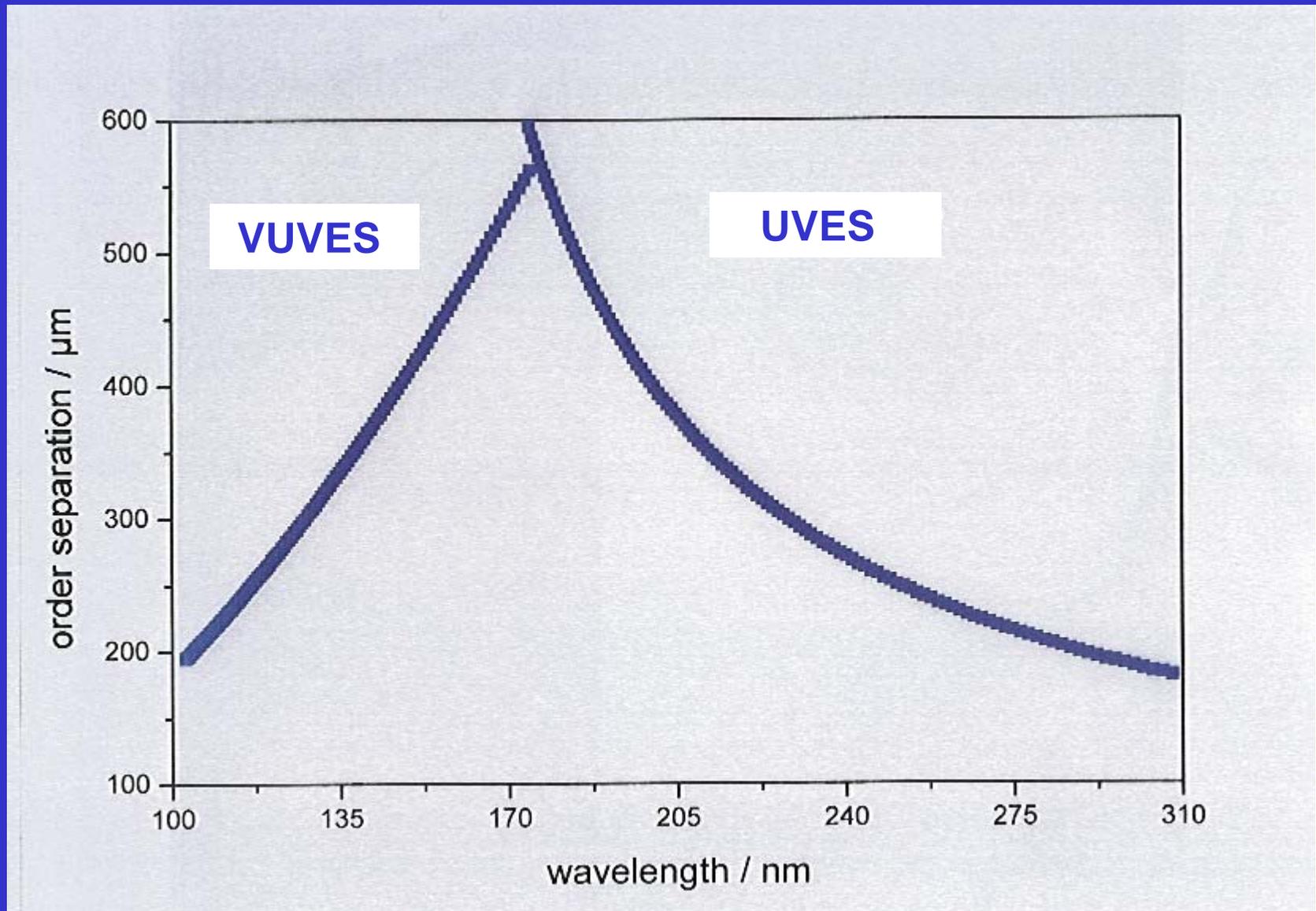
102.7700 nm



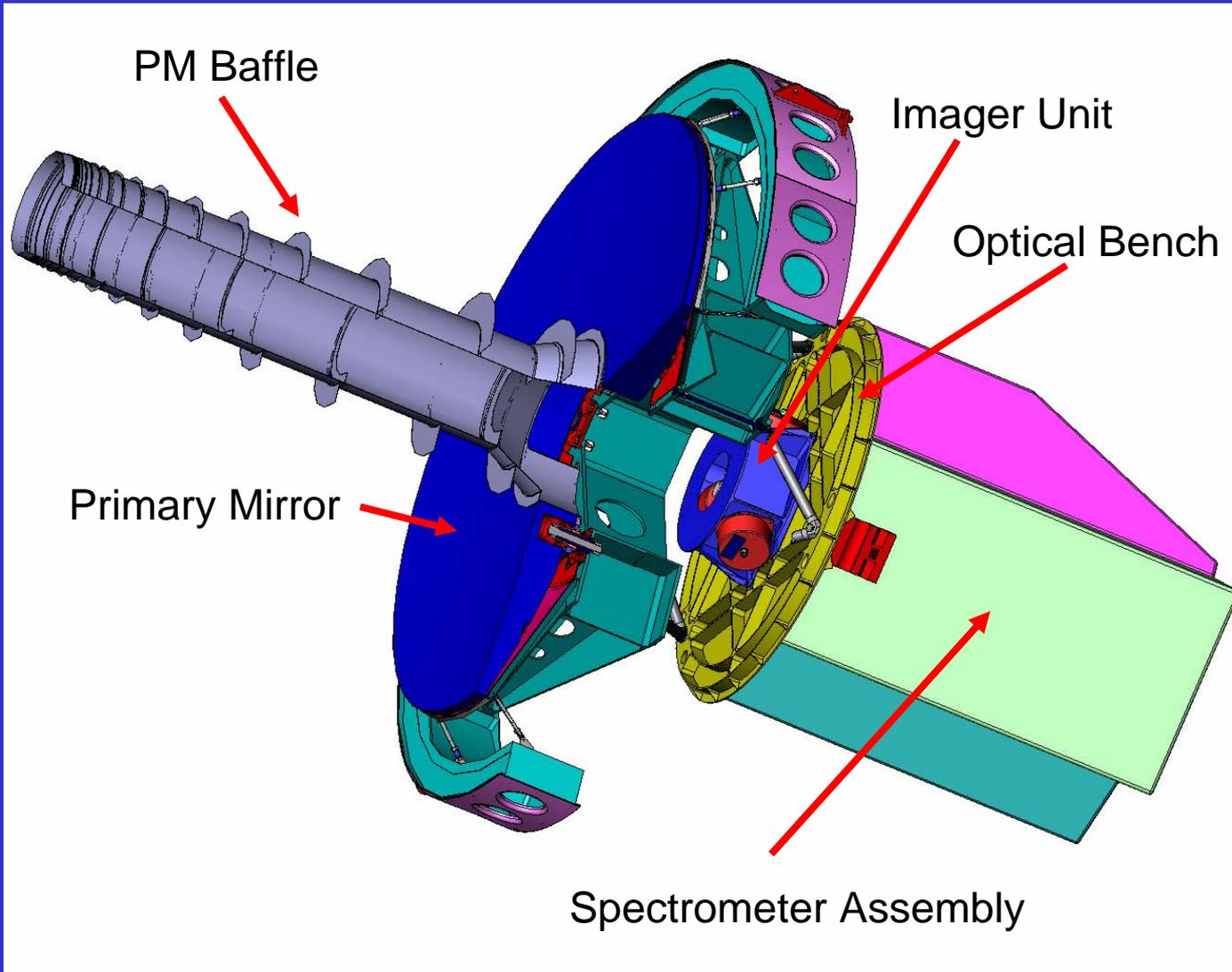
102.7718 nm



# WSO/UV Spectrographs

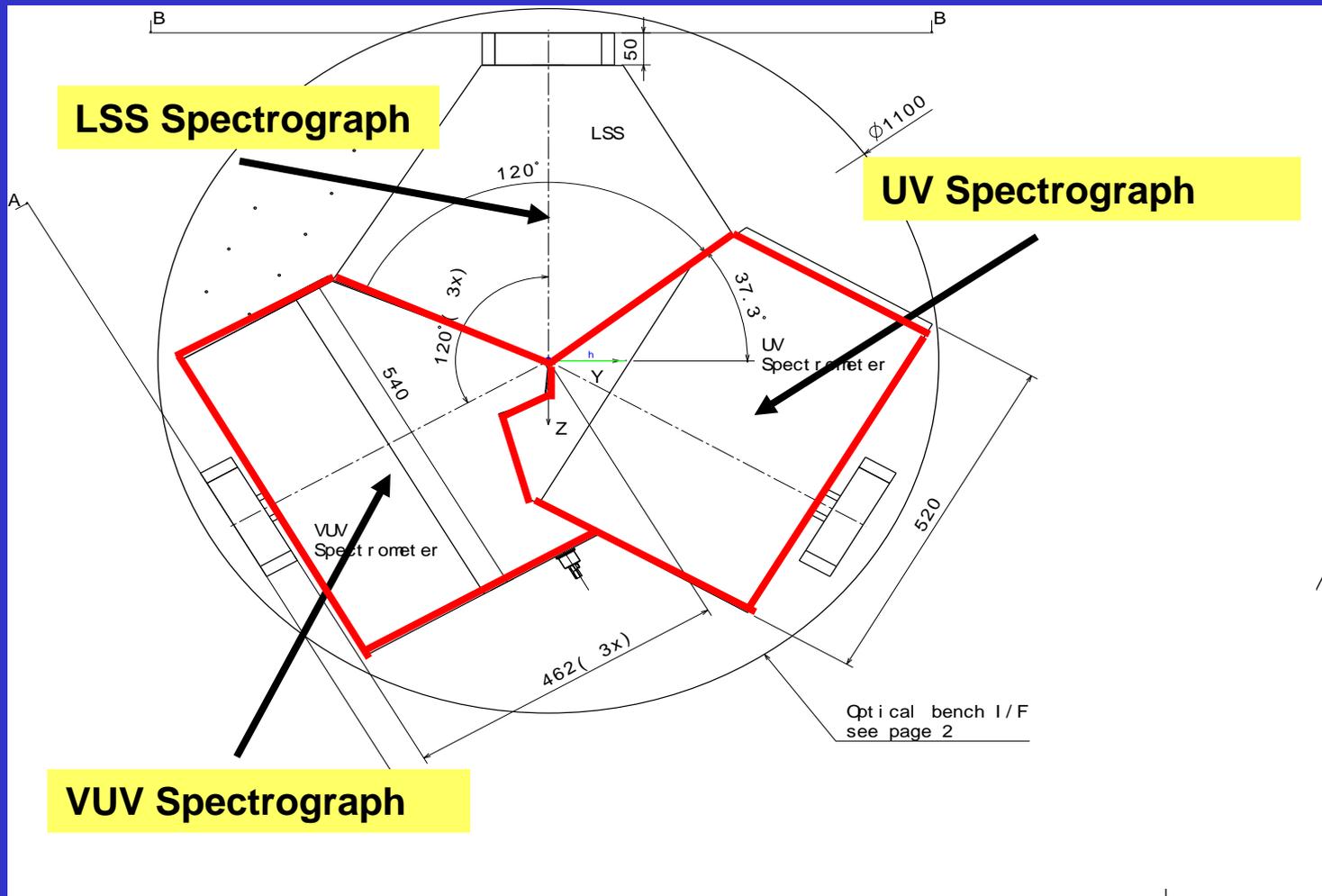


# WSO/UV Spectrographs

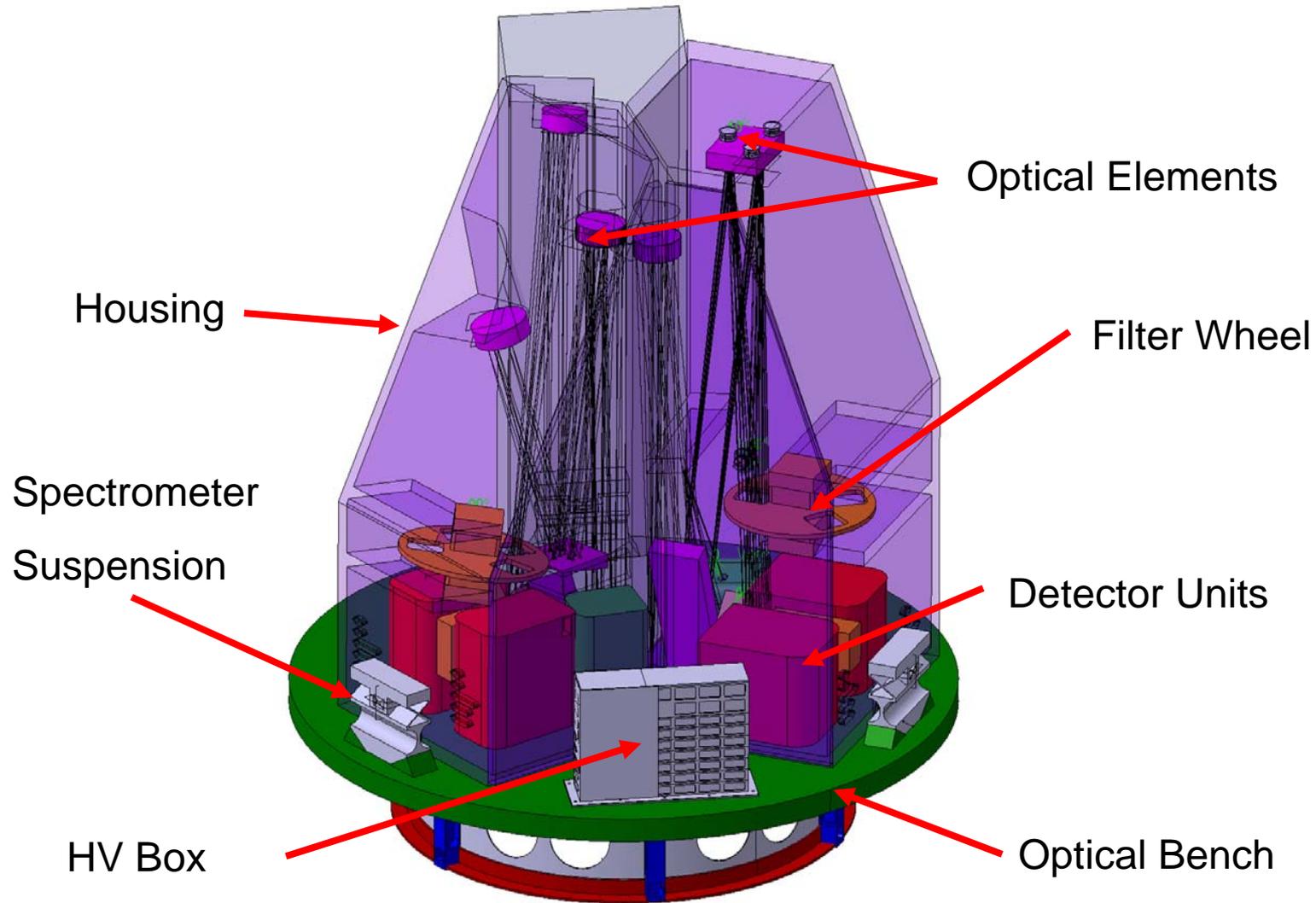


# WSO/UV Spectrographs

## Spectrographs Arrangement

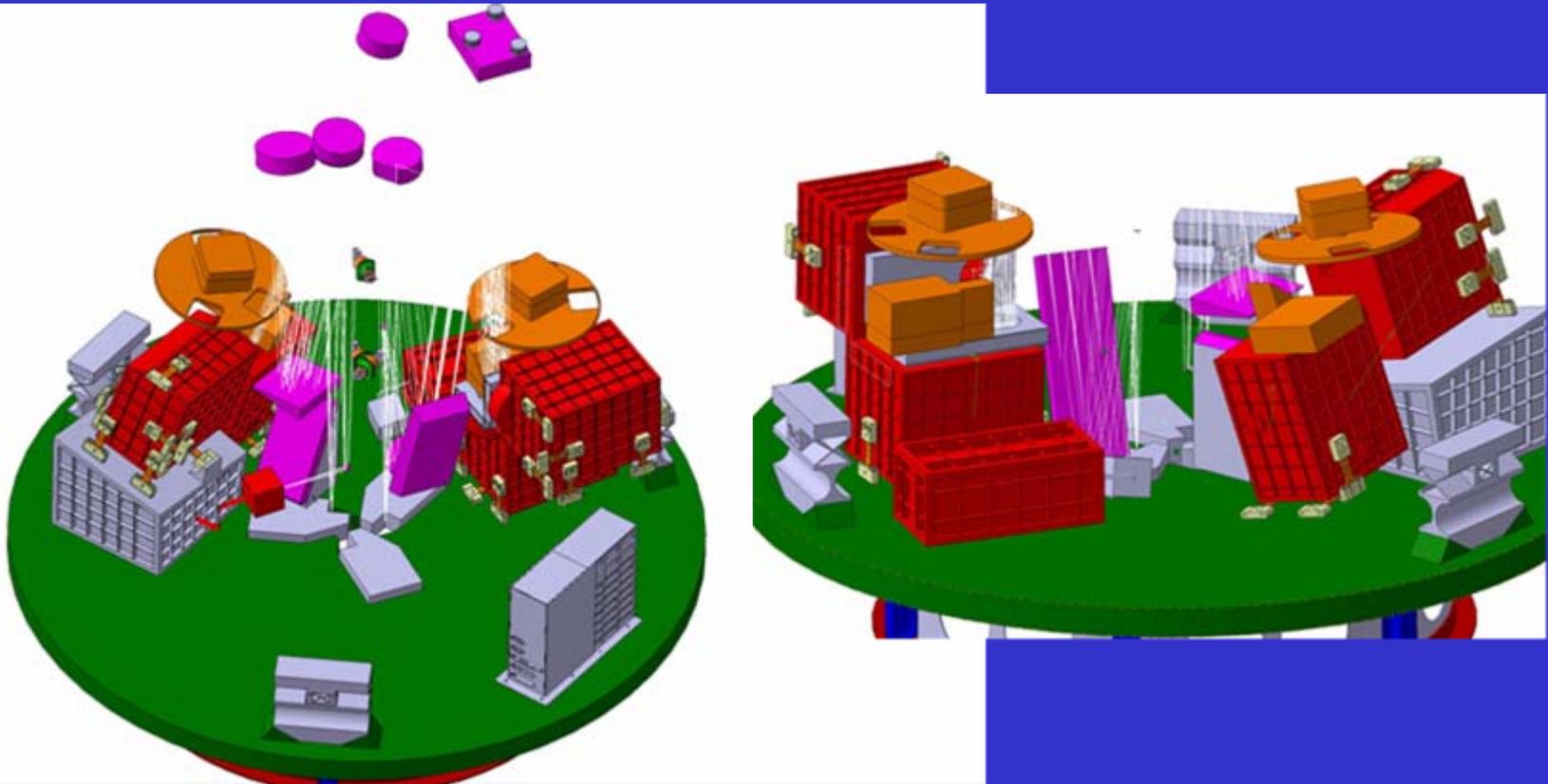


# WSO/UV Spectrographs Spectrometers with Housing

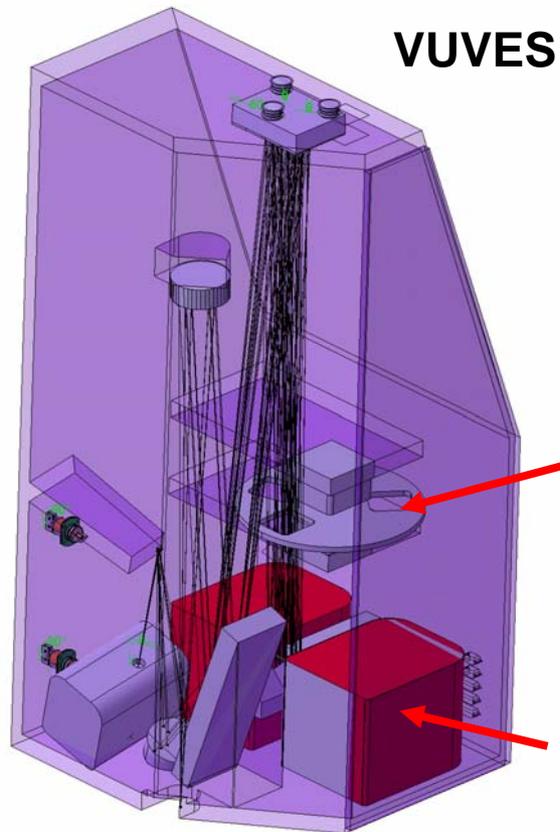


# WSO/UV Spectrographs

## Spectrometers without Housing

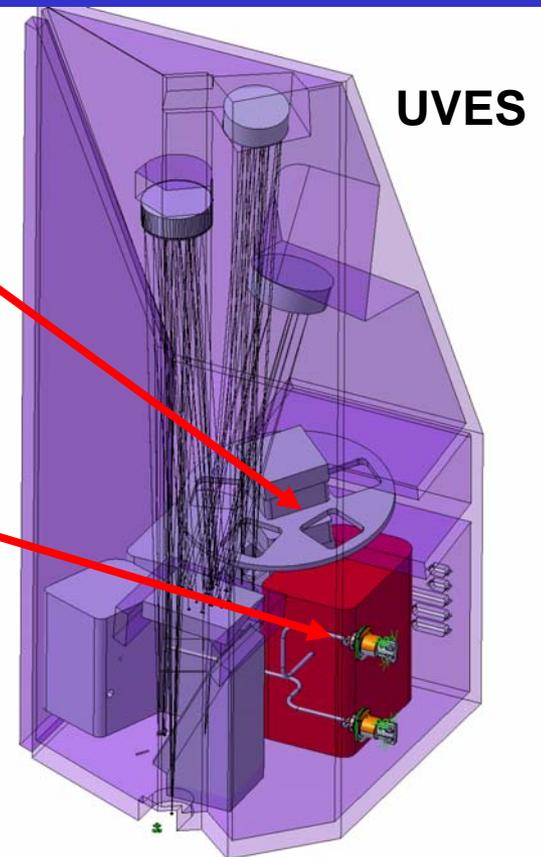


# WSO/UV Spectrographs



Filter Wheel

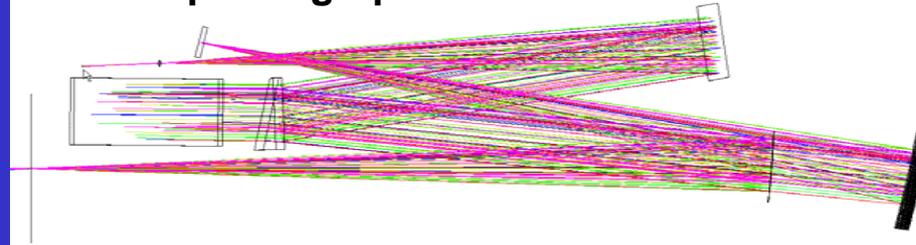
Detector Units



# WSO/UV Spectrographs

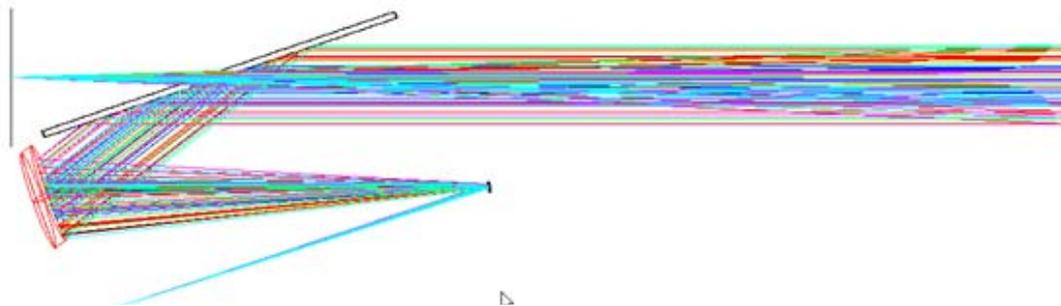
## In Field Guidance Sensor

### UV Spectrograph - In Field Fine Guidance



In field reflected at prism front surface towards focus mirror via lens onto fine guidance detector

### VUV Spectrograph - In Field Fine Guidance



In field decoupled from 0th order reflection of grating via 2 mirrors onto fine guidance detector

# WSO/UV Spectrographs

## ■ Phase A Baseline

Thermally unstable Aluminum structure

- 2 critical Focus Mechanisms ( Collimator Mirror , Echelle Grating)
  - Compensation of thermal gradients, temperature change, (drift)
  - Multi axes adjustment with very high accuracies required

	Translatoric Accuracy	Rotational Accuracy
Travel Range	200 $\mu\text{m}$	20 arcsec
Accuracy	5 $\mu\text{m}$	2 arcsec
Repeatability	2 $\mu\text{m}$	1 arcsec

- Critical In Orbit Operation to find best focus position

# WSO/UV Spectrographs

## Trade Off:

Thermomechanical Performance

Maturity

Costs

Candidate Materials:

Aluminum

Composite materials

Ceramics

## ■ Thermostable CeSiC Structure

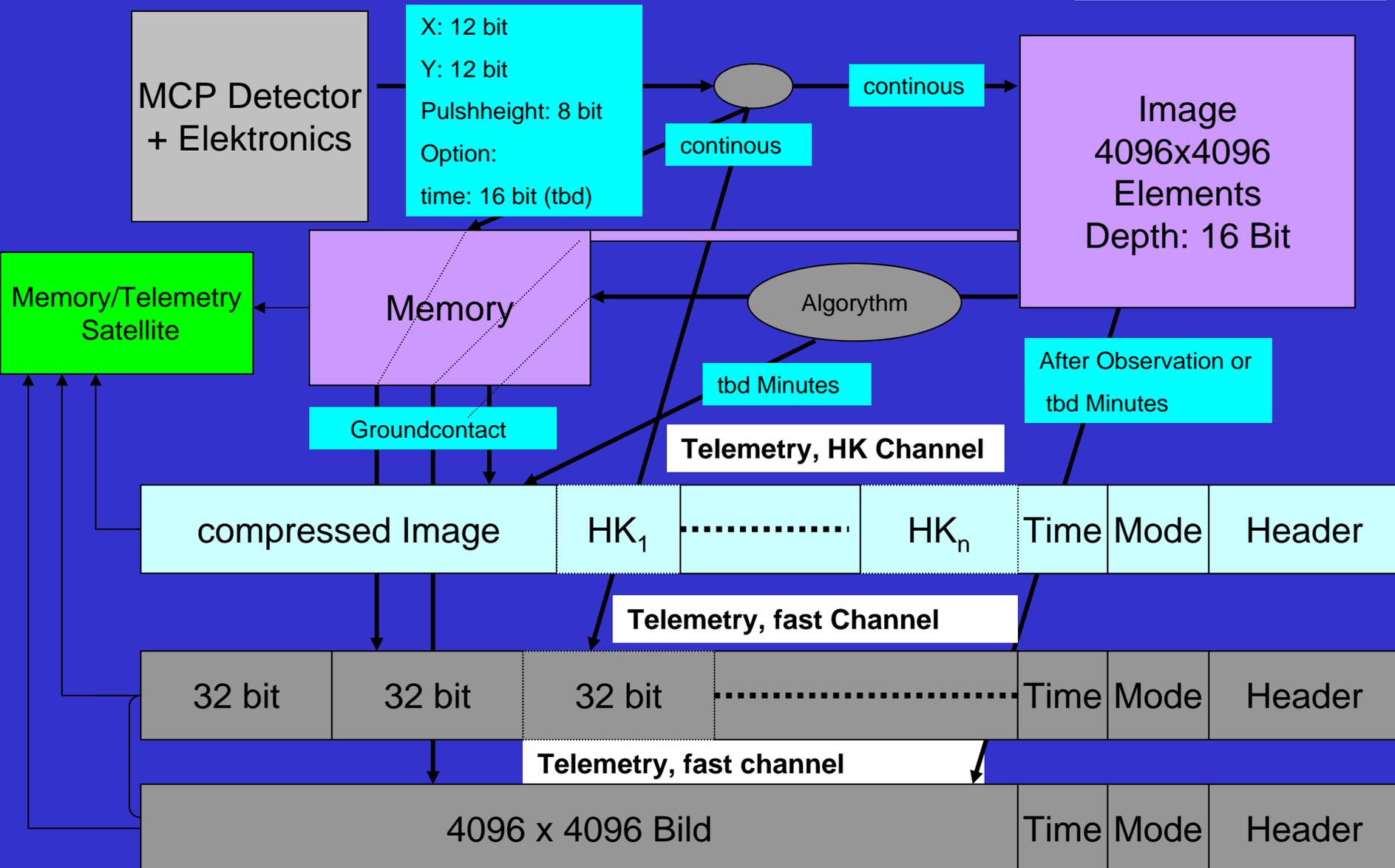
- ⇒ Required Spectral Resolution without Active Control of Optical Elements
- ⇒ Complex Collimator and Echelle Grating Mechanisms Skipped

# WSO/UV Spectrographs



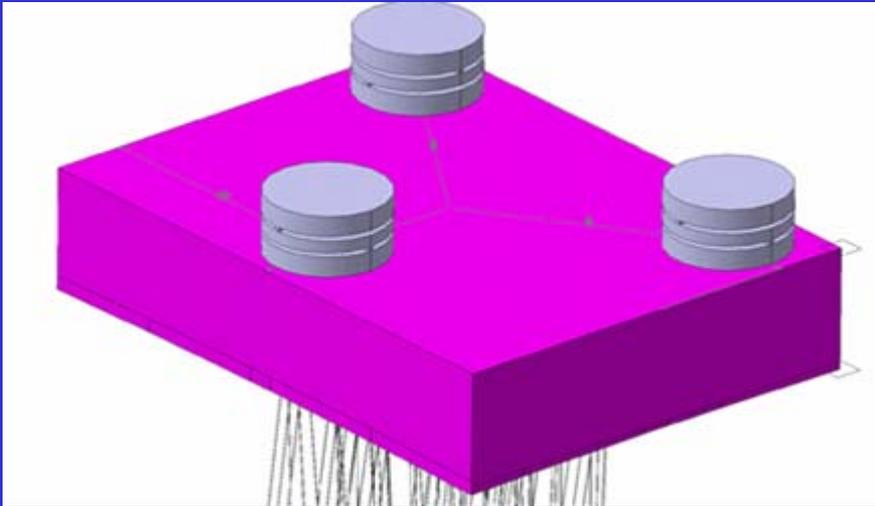
## CeSiC Test Structure

# WSO/UV Spectrographs



# WSO/UV Spectrographs

## Critical Components Design



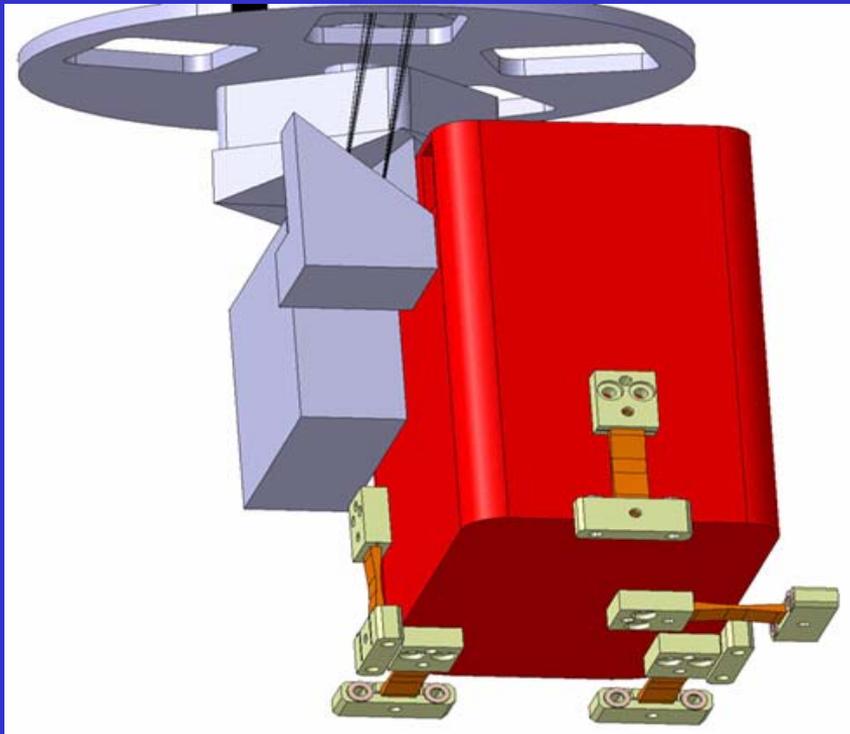
### Isostatic Mirror Suspension (ORFEUS Heritage)

#### Mirrors and Gratings

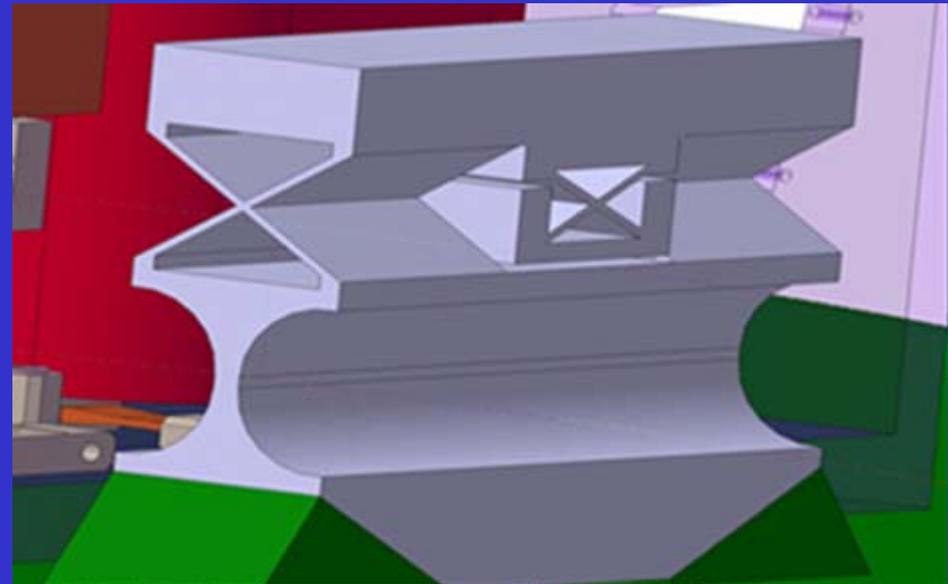
- Quartz Glas with Invar flexural mounts
- WFE:  $\lambda/20$  at  $\lambda = 633$  nm
- Surface Roughness:  $< 1$  nm
- Coatings:
  - UV : Al + SiO<sub>2</sub>
  - VUV: Al + MgF<sub>2</sub>
  - VIS: Al + SiO<sub>2</sub> (Option: Au)

# WSO/UV Spectrographs

## Critical Components Design

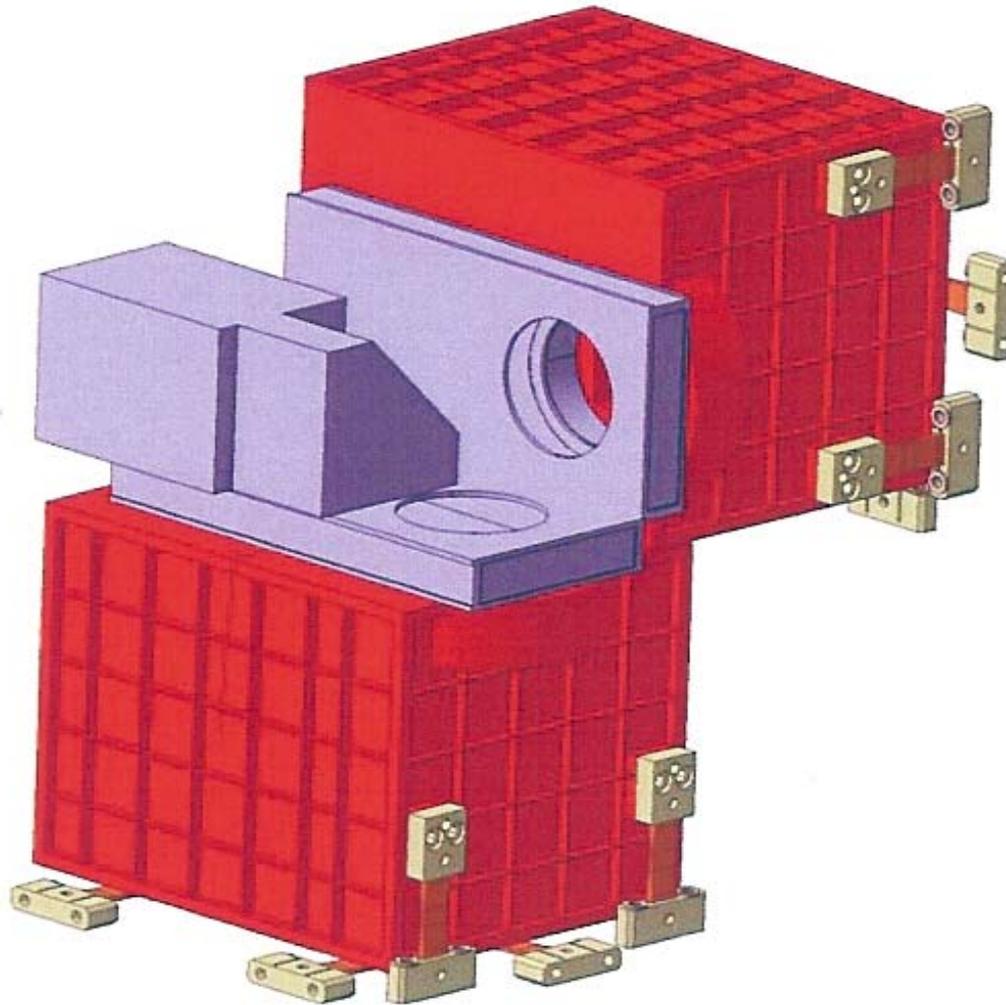


**Isostatic Suspension made from CFRP  
(PACS heritage)**



**Invar Suspension with SS flexural Blades  
(ORFEUS Heritage)**

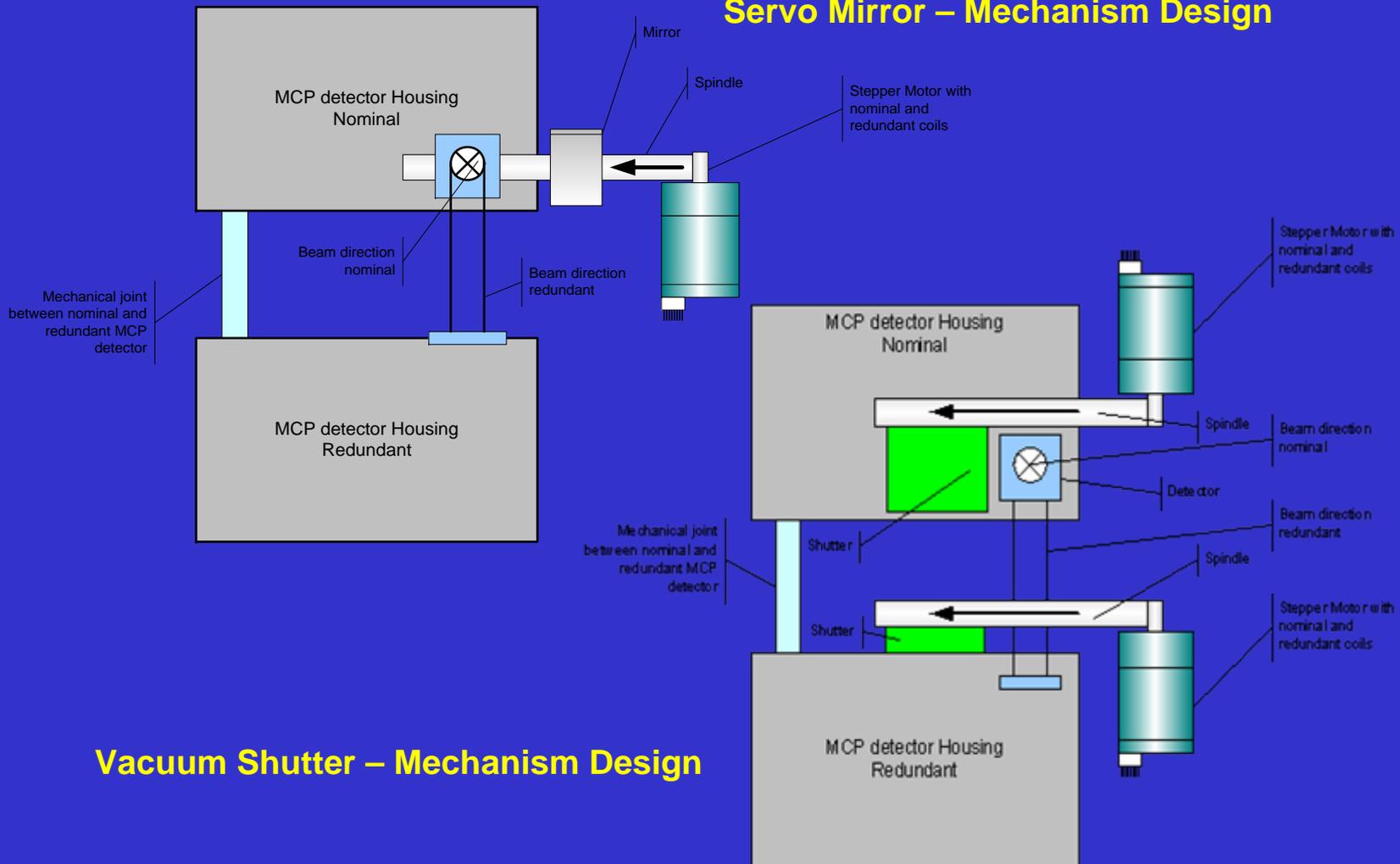
# WSO/UV Spectrographs



**MCP Detector Housing**

# WSO/UV Spectrographs

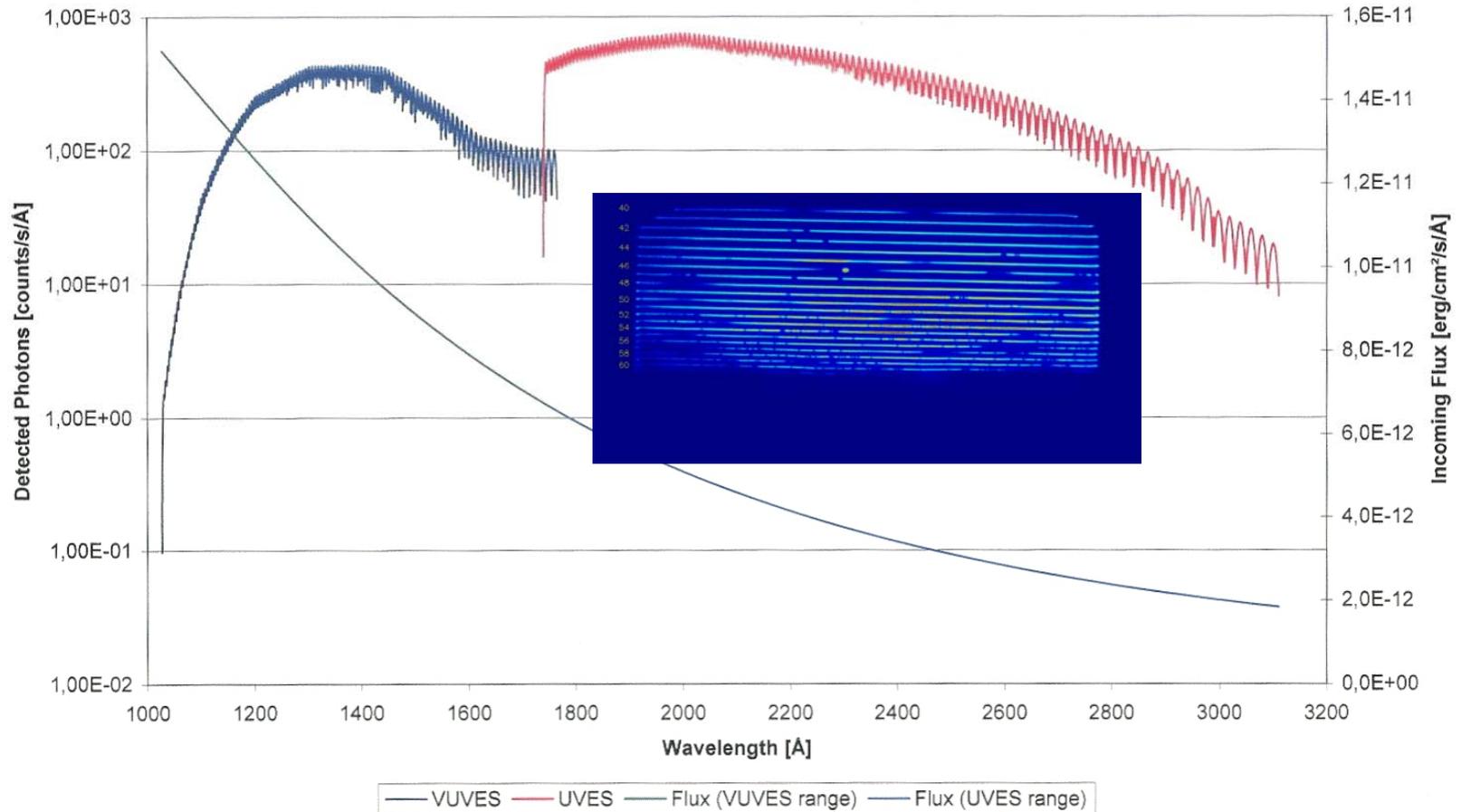
## Servo Mirror – Mechanism Design



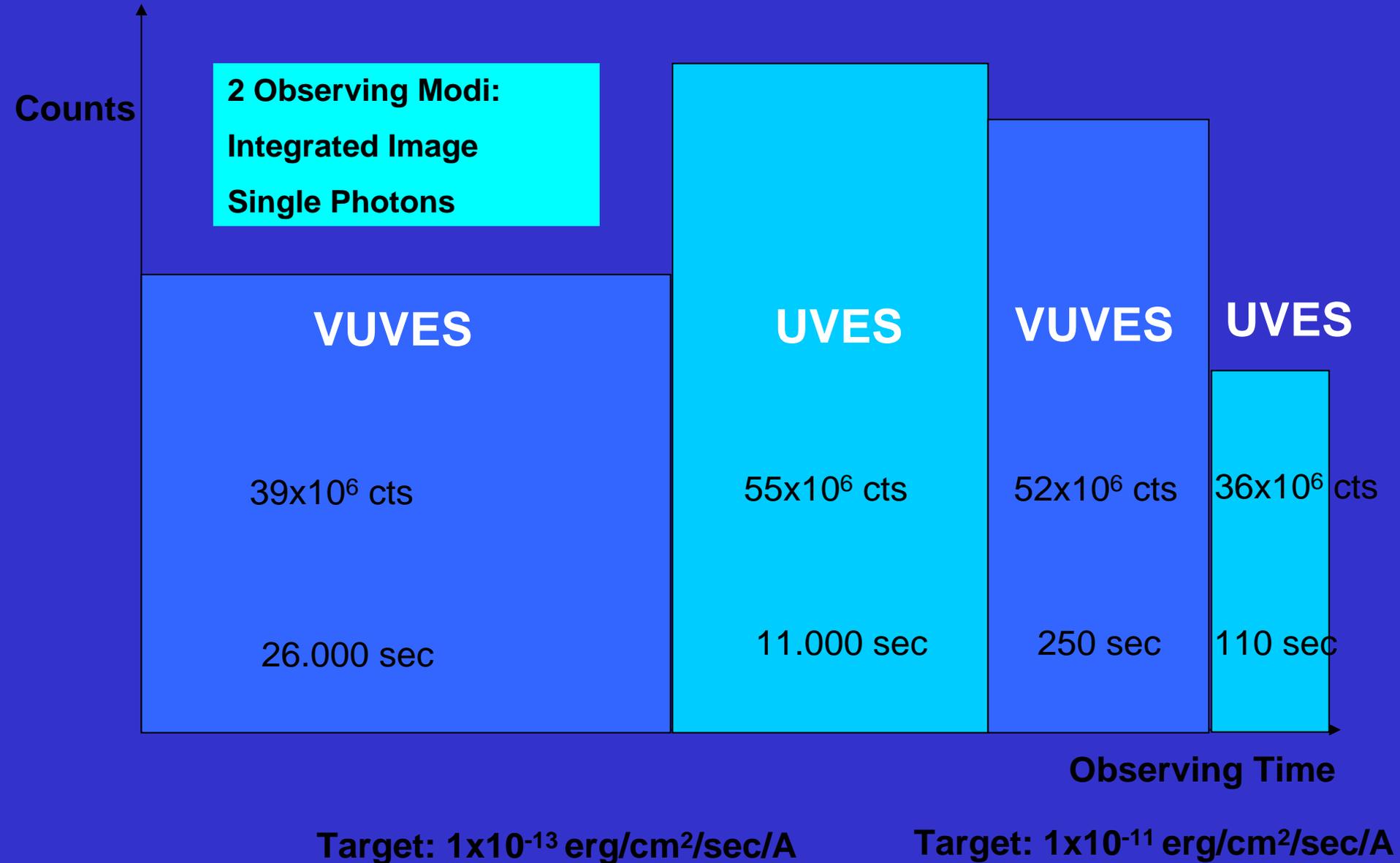
## Vacuum Shutter – Mechanism Design

# WSO/UV Spectrographs

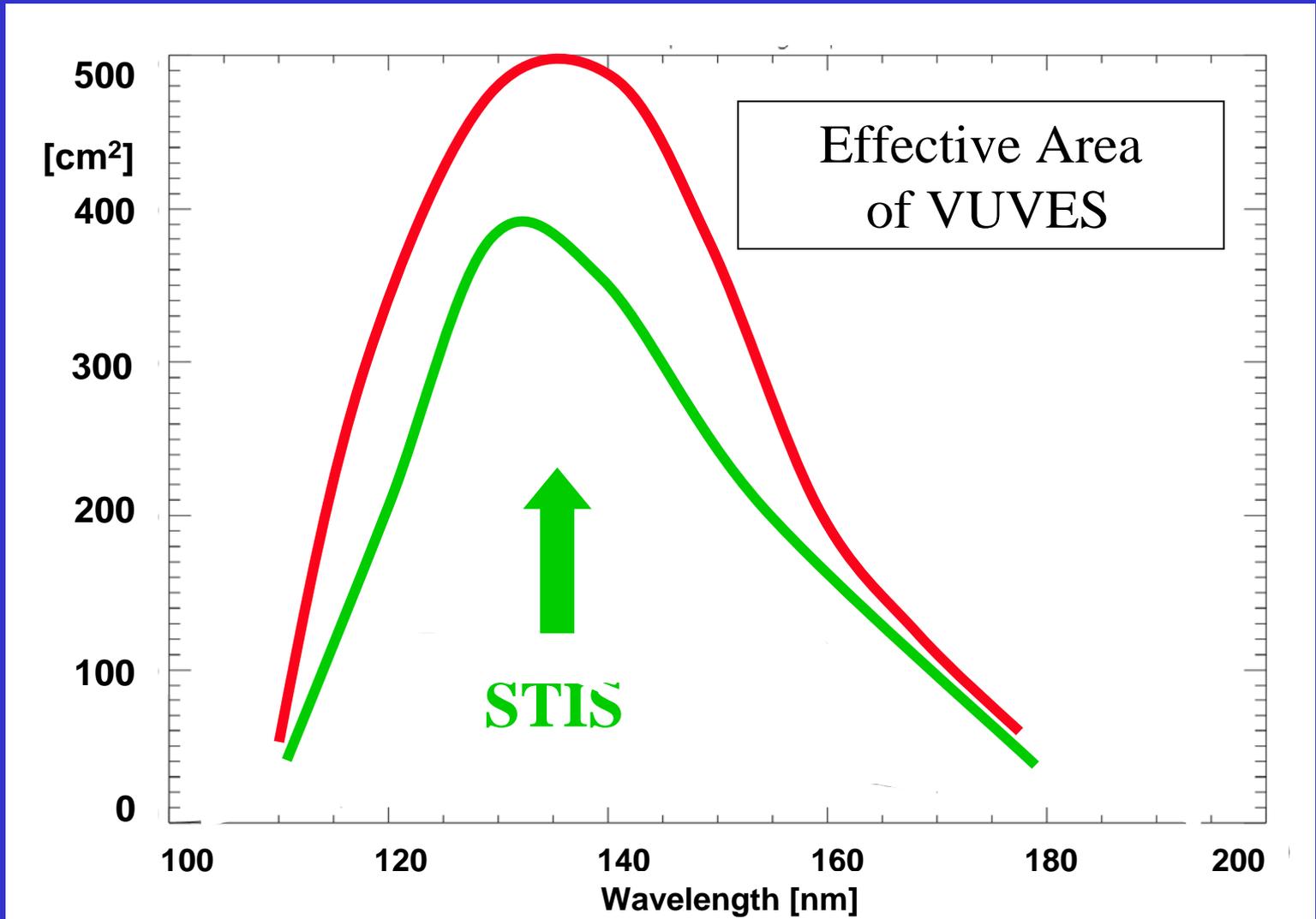
Detected Count rates for a Blackbody Model Spectrum



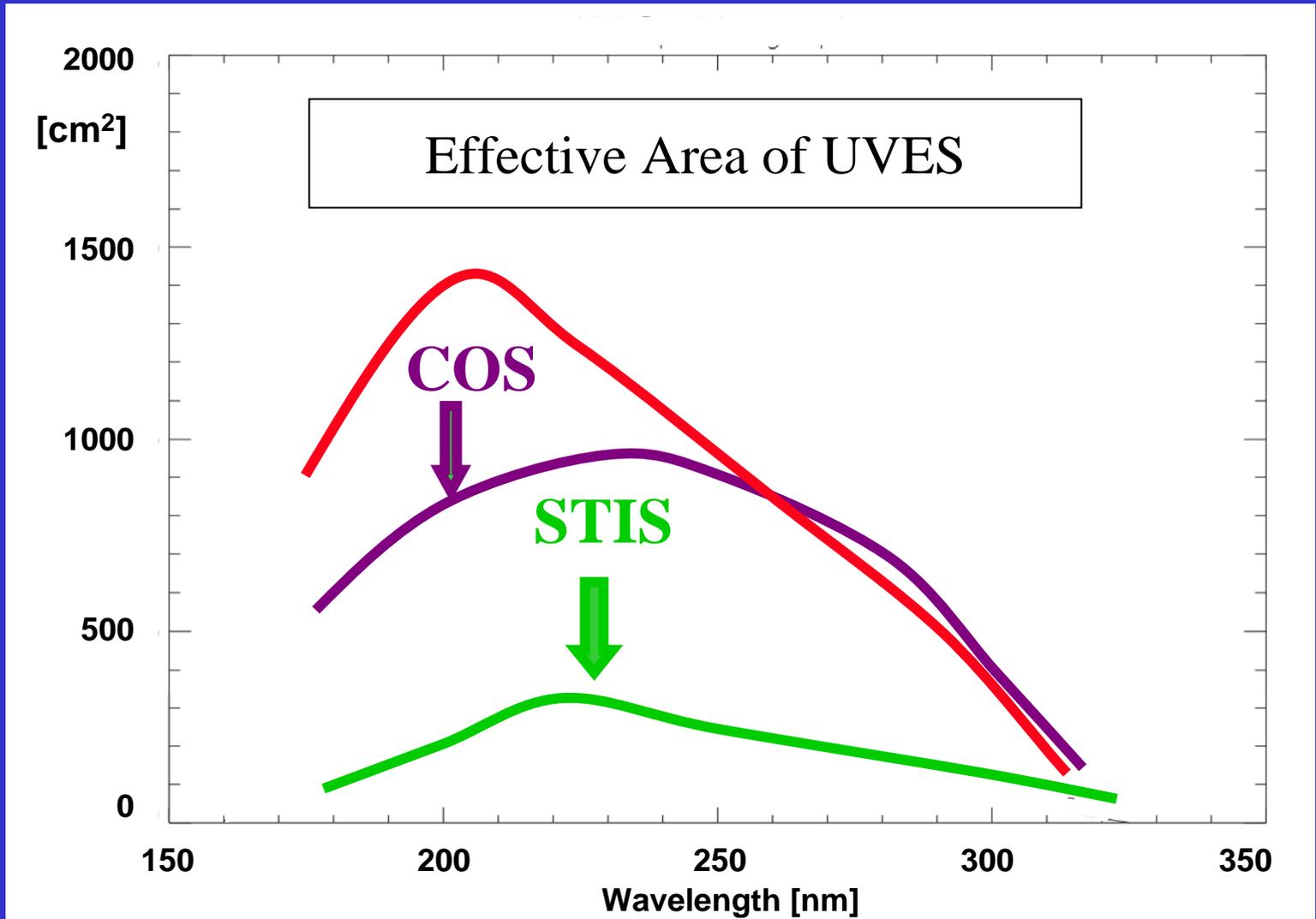
# WSO/UV Spectrographs



# WSO/UV Spectrographs



# WSO/UV Spectrographs



# WSO/UV Spectrographs

## Comparison with HST-COS:

Wavelength Range    Resolving Power    Eff. Area (cm<sup>2</sup>)

115 – 145    20.000 – 24.000    2.200

VUVES

140 – 178    20.000 – 24.000    1.200

170 – 210    20.000 – 24.000    600

UVES

210 – 250    20.000 – 24.000    700

250 – 320    20.000 – 24.000    450

123 – 205    2.500 - 3.500    1000

170 – 320    1.550 - 2.900    500

# WSO/UV Spectrographs

Element	Risk Type	Risk Mitigation Strategy
MCP	Schedule risk due to customized MCP development and technical risks (quantum efficiency; Coatings)	<ul style="list-style-type: none"> <li>■ Selection of experienced stacks developer (Hamamatsu);coating facilities, etc.)</li> <li>■ Use of FEE heritage partly available at IAAT</li> <li>■ <b>Early MCP procurement &amp; bread boarding</b></li> </ul>
IFGS	Schedule risk due to customized CMOS development	<ul style="list-style-type: none"> <li>■ Selection of experienced CMOS developer (Fill Factory)</li> <li>■ Adequate Subcontractor control;</li> </ul>
Structural materials and Hybrid Structure (CeSiC; Invar, Quartz Glas)	Technical risk due to missing space qualification	<ul style="list-style-type: none"> <li>■ Extensive technology programs performed by ECM (ESA contract)</li> <li>■ Qualification to be performed in phase B</li> <li>■ Potential fallback: Space qualified C/SiC (Astrium F); but not considered for baseline approach</li> </ul>

# WSO/UV Spectrographs

END

